CVC 4 - Silicone Diffusion Pump Fluid

Tetramethyltetraphenyl trisiloxane rich fluid for producing high vacuums in the range 10⁻⁸ Torr. Exhibits excellent chemical, oxidation, thermal, hydrolysis and radiation resistance. Extremely low back streaming properties

Features:

- Good resistance to high temperature breakdown
- Ultra high vacuum performance
- Extremely low back streaming properties
- Rapid pump down
- Safer to use than hydrocarbon diffusion pump fluids

Pack sizes:

500cc, 1 kg, 5 kg, 20 kg Further technical information is available upon request.

Applications:

For particularly tough rugged applications requiring rapid pump down :-

- Vapour deposition of thin films by sputtering or evaporation, electron beam operations and high vacuum furnaces, melting, degassing and sintering, refractory metals and thick film deposition.
- Also suitable for all aspects of vacuum coating such as optics and automotive components
- UHV characteristics particularly useful for thin film, surface technology, thermonuclear and plasma physics applications







Typical characteristics:

Specific Gravity gcm ⁻³ @ 25°C	1.07
Viscosity cSt @ 25°C	40 typical
Flash Point Open Cup°C	>210
Boiling Point (under vacuum) °C	230 typical
Ultimate Pressure Torr	10 ⁻⁸ - 10 ⁻⁹



GBR TECHNOLOGY LIMITED

GBR Technology Ltd

Units 6-8, Jupiter House, Calleva Park, Aldermaston, Reading, Berkshire, RG7 8NN, United Kingdom Telephone: +44 (0)118 982 0567 Fax: +44 (0)118 982 0590 Email: info@gbrtech.co.uk www.gbrtech.co.uk

